

## PATENT ASSIGNMENT COVER SHEET

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<b>SUBMISSION TYPE:</b>	NEW ASSIGNMENT
<b>NATURE OF CONVEYANCE:</b>	ASSIGNMENT
<b>CONVEYING PARTY DATA</b>	
<b>Name</b>	<b>Execution Date</b>
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<b>Property Type</b>	<b>Number</b>
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<b>DATE SIGNED:</b>	09/12/2015

**Total Attachments: 1**

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## ASSIGNMENT

The subject of this Assignment is the following four related patent applications: US Ser. No. 61/951,591, filed 12 March 2014; US Ser. No. 61/978,667, filed 11 April 2014; US Ser. No. 14/645,654, filed 12 March 2015; and international application no. PCT/US2015/020218, filed 12 March 2015, each titled Aluminum Superalloys for Use in High Temperature Applications and hereinafter referred to collectively as "the subject patent applications."

The three joint inventors of each of the subject patent applications are Nhon Q. Vo, residing in Skokie, Illinois; David N. Seidman, residing in Skokie, Illinois; and David C. Dunand, residing in Evanston, Illinois. The three joint inventors previously assigned their rights, titles and interests in the subject patent applications to NanoAL LLC, a Delaware corporation have a place of business at 8025 Lamon Avenue, Suite 446, Skokie, Illinois 60077.

For valuable consideration, adequacy and receipt of which is hereby acknowledged, NanoAL LLC hereby assigns back to David N. Seidman and to David C. Dunand, respectively, whatever rights, titles and interests they originally had in the subject patent applications, including all rights of priority resulting from the filings of the subject patent applications.

NanoAL LLC

 Date: 08/13/2015

By: Nhon Q. Vo

Title: Chief Technology Office